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## Mesoporous Thin Film WO<sub>3</sub> Photoanode for Photoelectrochemical Water Splitting: A Sol-Gel Dip Coating Approach

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A facile and cost-efficient method to fabricate a mesoporous structured WO<sub>3</sub> photoanode was implemented for use in a tandem dual water splitting photoelectrochemical cell. Semi-transparent thin films of tungsten trioxide were fabricated by sol-gel process, incorporating a block co-polymer to induce a template-directed mesoporous structure. These thin films are deposited by dip coating onto transparent conducting oxide substrates and crystallized at a low temperature of 400°C in air. These thin film photoanodes exhibit a photocurrent of up to 0.6 mA/cm<sup>2</sup> in potassium phosphate buffers of pH 2, 4, and 6 at 1.23 V vs. RHE under 300 mW/cm<sup>2</sup> visible (400 – 900 nm) light irradiation with a faradic efficiency of up to 75%. Furthermore, we have demonstrated that corrosion occurs in electrolytes of pH > 4. The faradic efficiencies in varying pH solutions however suggest that parasitic redox reactions occurs in acidic conditions, limiting the O<sub>2</sub> production and demonstrating the need for stable surface co-catalysts to increase faradic efficiencies. In neutral conditions, protective layers and/or co-catalysts are needed for increasing WO<sub>3</sub> photoanode stability.

### 1. Introduction

Due to the increasing demand for energy, the development of renewable fuels is imperative to account for the decrease of fossil fuels which will become scarce in the near future. Hydrogen is a promising energy carrier which could potentially aid in weaning off fossil fuel dependency. An attractive solution is to directly convert solar energy into hydrogen which can be stored and re-used in the chemical (fertilizer production by the Haber-Bosch process) as well as energy industries, transportation, etc. One of the most promising potential approaches to this issue is the concept of water splitting photoelectrochemical cells (PECs) which combines the concepts of photovoltaics and electrolyzers - two types of technologies which are presently well developed, mature technologies.<sup>1-4</sup>

One of the challenges of this technology is to find suitable and robust materials for both light harvesting and catalysis of

the oxygen and hydrogen evolution reactions. Metal oxides are encouraging materials due to the fact that they possess photovoltaic effect and are stable in aqueous solutions, which enables them to avoid potential competitive redox reactions associated with degradation and corrosion.<sup>5</sup> Tandem PECs combine two photoelectrode materials generally an n-type semiconductor photoanode for the OER and p-type semiconductor for the HER. As most large band gap materials are n-type semiconductors, this designates them as appropriate photoanode candidates. The first discovery of photocatalytic characteristics in metal oxides was reported in 1972 by Fujishima and Honda using rutile TiO<sub>2</sub>.<sup>6</sup> Since then, many metal oxides, notably,  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub>, WO<sub>3</sub>, anatase TiO<sub>2</sub>, and BiVO<sub>4</sub>, have been investigated as n-type photoanode materials for the water oxidation half reaction. These photoanode materials have been additionally coupled with numerous surface co-catalysts to increase their efficiency by decreasing the photocurrent onset/overpotential, increasing faradic efficiencies, and avoiding parasitic reactions and degradation which may compete with water splitting reactions. Typical co-catalysts used for the OER on n-type photoanodes are cobalt phosphate (Co-Pi)<sup>7-11</sup>, Co<sub>3</sub>O<sub>4</sub><sup>12, 13</sup>, MnO<sub>2</sub><sup>14</sup>, FeOOH<sup>15, 16</sup>, NiOOH<sup>17, 18</sup>, IrO<sub>2</sub><sup>19, 20</sup>, RuO<sub>2</sub><sup>21</sup>, RhO<sub>2</sub><sup>13</sup>, or Pt.<sup>22</sup>

Tungsten trioxide has been studied extensively as a n-type photoanode material for water oxidation in photocatalytic

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systems.<sup>23</sup> It was the subsequent material selection regarding metal oxide materials for water splitting photoanodes following the discovery of  $\text{TiO}_2$ .<sup>24</sup>  $\text{WO}_3$  typically possesses a band gap of 2.7 eV, slightly smaller than that of anatase  $\text{TiO}_2$  of 3.2 eV, thus enabling increased absorption of the solar spectrum (e.g.  $\text{WO}_3$  can utilize 12% of the solar spectrum; whereas  $\text{TiO}_2$  can only harness 4%).<sup>25</sup> Despite the narrow range of light absorption towards the ultraviolet range of the light spectrum,  $\text{WO}_3$  photoanodes typically display larger steady state photocurrents than  $\alpha\text{-Fe}_2\text{O}_3$  photoanodes due to the higher incident photon to current efficiency (IPCE).<sup>26</sup>  $\text{WO}_3$  possesses inherently good electron transport.<sup>27</sup> The hole diffusion length in  $\text{WO}_3$  is believed to be 150 nm while  $\alpha\text{-Fe}_2\text{O}_3$  has a limited hole diffusion length of only 2 – 4 nm.<sup>23, 28</sup> Thus,  $\text{WO}_3$  is advantageous compared to both  $\text{TiO}_2$  and  $\alpha\text{-Fe}_2\text{O}_3$  for solar absorption.

Metal oxides, specifically  $\text{WO}_3$ , can be fabricated using several techniques: drop-casting<sup>28</sup>, anodization<sup>29-33</sup>, electrodeposition<sup>9, 34-36</sup>, chemical vapor deposition<sup>37</sup>, spray pyrolysis<sup>38</sup>, magnetron sputtering<sup>39</sup>, e-beam evaporation<sup>40</sup>, doctor blade<sup>41-43</sup>, and spin-coating.<sup>44, 45</sup> Nanostructuring<sup>46, 47-49</sup> and doping have been shown to increase photocurrents by augmenting the surface area between the semiconductor and electrolyte, as well as decreasing the distance between the production sites of holes and the interface where they are used to produce oxygen.

This article examines easily fabricated, low cost, thin film, semi-transparent, mesoporous,  $\text{WO}_3$  as an n-type photoanode for water splitting application in a dual photosystem device. These  $\text{WO}_3$  photoactive thin films are fabricated by an inexpensive, robust, reproductive, sol-gel dip coating technique, which is easily scalable and transferrable to industrial application.

## 2. EXPERIMENTAL

**2.1. Synthesis.** Ethanol (99.9% ACS reagent AnalaR NORMAPUR) and tetrahydrofuran (THF, 99.9% ACS reagent AnalaR NORMAPUR) purchased from VWR.  $\text{WCl}_6$  (99.9% trace metal basis),  $\text{KH}_2\text{PO}_4$  ( $\geq 99.995\%$  TRACESELECT),  $\text{K}_2\text{HPO}_4$  ( $\geq 99.9\%$  ACS reagent) as well as  $\text{H}_3\text{PO}_4$  were purchased from Sigma Aldrich. Poly(isobutylene-*b*-ethylene oxide) (#P4793-IbEO or #P4792-IbEO) was purchased from Polymer Source.

4.4 mL of ethanol were mixed with 1.6 mL THF with 100 mg of PIB-*b*-PEO in a closed vial and then placed in an oven at 70°C until the block co-polymer was dissolved. Finally, 1 g  $\text{WCl}_6$  was added to the cooled solution containing the polymer (0.28 M final tungsten concentration). An exothermic reaction occurred, evolving chlorine gas which was vented, and the solution is left to stir for at least 1 hour resulting in a turquoise-blue solution. The block co-polymer was omitted in the sol for dense  $\text{WO}_3$  thin films preparation. Fluorine doped tin oxide (FTO) transparent conducting oxide substrates (Solems Asahi-100), consisting of 80 nm FTO (approximately 80  $\Omega$ /square) on 1.1 mm glass substrates which were rinsed with ethanol before thin layers were

deposited. The hybrid solution was deposited on the FTO substrates by dip coating technique at 2.7 mm/s at low relative humidity (measured with HANNA thermohygrometer HI9564) at room temperature with an annealing treatment at 350°C for 2 – 5 minutes in a ceramic plate oven in air between each layer depositions. In total, each layer deposition measured about 70 nm, and several layers were consecutively dipped to increase the thickness as to increase the light absorption for better performance. In total, 8 layers were deposited by dip coating and final thermal treatment/calcination was effectuated between 400 – 550°C for 30 minutes in a ceramic oven in air.

**2.2. Characterization.** UV-visible light absorption and transmission was measured with an Agilent Technologies Cary Series 5000 UV-visible-near infrared spectrometer using a double beam with a background of FTO defined. X-ray diffraction patterns were taken using Bragg-Brentano flat-specimen geometry on all the samples using a high-resolution Bruker D8 diffractometer using  $\text{CuK}\alpha$  radiation and equipped with a linear position sensitive detector. The diffraction patterns were refined using the Rietveld program Xnd.65 Field emission gun scanning electron microscopy (FEG-SEM) was effectuated using a Hiatchi Oxford x-max beam SU-70 with a 50 mm<sup>2</sup> tungsten filament at 10 – 15 kV. Material elements were also detected using the Hiatchi Oxford microscope for energy-dispersive X-ray spectroscopy (EDX). High resolution transmission electron microscopy (HR-TEM) was done using a JEOL JEM-2010.

**2.3. Photoelectrochemical.** Photoelectrochemical measurements were completed with an AMETEK Solartron Analytical Modulab potentiostat which measured a linear voltage sweep (LVS) of dark and illuminated samples in a 3 electrodes setup. The LVS sweeps were effectuated from 0 V to 1.8 V vs.  $\text{Ag/AgCl}$  KCl saturated reference electrode (ALS Co. LTD RE-1C referenced 0.197 V vs. NHE) with a platinum wire as a counter electrode using a 10 mV/s scan rate. All current density curves were referenced to the reversible hydrogen electrode (RHE), according to the equation:  $E \text{ vs. RHE} = E \text{ vs. Ag/AgCl} + E^0(\text{Ag/AgCl}) (0.197) + 0.059 \times \text{pH}$ . The geometric active area of the  $\text{WO}_3$ , which acts as the working electrode, is defined by Hi-Bond polyamide scotch tape (HB830-19) which measured 0.2 cm<sup>2</sup> for LVS and 1 cm<sup>2</sup> for faradic efficiency measurements. Electrical contacts were made by conductive copper scotch (3M Scotch 1245) which was adhered directly to the FTO exposed portion of the photoelectrode. All solutions used were 1 M potassium phosphate buffers in order to compare different pH values (2, 4, and 6) while maintaining the same ionic force and anion composition. The output power of the Xenon lamp was measured using a Newport 1918-R photodiode. Photocurrent density is measured 50 cm away from a 300 W Xenon lamp (Newport Xe ozone free lamp model 6258) working at 280 W equipped with an IR water filter Oriel Liquid Filter 61945 (250 – 950 nm). The Xenon lamp output was 300 mW/cm<sup>2</sup> for visible light (400 – 900 nm) and 350 mW/cm<sup>2</sup> for visible and

ultraviolet light. *J-V* curves were performed either under 300 mW/cm<sup>2</sup> (when visible light was considered) or 350 mW/cm<sup>2</sup> (when both visible and ultraviolet light were considered). On the *J-V* curves, the experimental conditions are reminded.

Stability and faradaic efficiency of the 500 nm mesoporous WO<sub>3</sub> film was performed under visible light, *i.e.* 300 mW/cm<sup>2</sup>.

550 nm of mesoporous WO<sub>3</sub> under AM1.5G illumination, back illuminated in 1M H<sub>2</sub>SO<sub>4</sub> (black) and with 1M Na<sub>2</sub>SO<sub>3</sub> (red) 50cm from the lamp (standard) with a Pt counter, Ag/AgCl (KCl saturated) reference using a LVS from -0.2 to 1.8V vs. ref with a step of 10mV and newport 81088A Air Mass Filter, AM 1.5 Global and a Newport (Xe 300W Ozone free) lamp 67001. Visible light measurements were possible using a 400 nm UV filter Oriel UV filter 51272 (cut off 400 nm). A Newport electronic shutter (model 76994) was also used for chopped light measurements with controller (model 76995, combined with a Jeulin very low frequency generator reference 293049).

All electrochemical experiments were performed with BACK SIDE illumination, as tests suggest the photoelectrochemical performance is similar for both back and front side illumination – thus in the final dual tandem PEC configuration the photoanode will be illuminated from the back.

**2.4. Stability and Faradic measurements.** Stability and faradic measurements were tested in a laboratory fabricated air tight H-cell with a plastic window allowing a 3-electrode setup separated by glass frits. Oxygen in the headspace of the cell was detected with a Perkin Elmer Clarus 580 gas chromatograph TCD at 32°C with nitrogen carrier gas. Oxygen in solution was measured simultaneously with a Unisense Ox-N 13987 Clark electrode calibrated at 40°C (due to increase in solution temperature under illumination during testing) with a two point calibration in air saturated solution and deoxygenated solution.

**2.5. Electrocatalyst deposition.** Cobalt phosphate was photoelectrodeposited onto the WO<sub>3</sub> in pH 6 using a 0.5 mM cobalt concentration in 0.1 M potassium phosphate solution. The deposition was completed for 1, 5, or 10 minutes with 300 mW/cm<sup>2</sup> illumination with platinum mesh counter electrode (2 cm<sup>2</sup> active area exposed to catalyst deposition – back illuminated). Samples were rinsed with deionized water and dried with compressed air after deposition. 5 minute depositions were found to be the most performant of the varied deposition times and resulting in dispersed cobalt over the WO<sub>3</sub> surface.

### 3. RESULTS AND DISCUSSION

#### 3.1. Structure.

Calcination treatment of the thin films at 400°C resulted in a distorted  $\beta$ -orthorhombic/ $\gamma$ -monoclinic WO<sub>3</sub> structure with crystal orientation preferential to the (1 0 0) plane modeled

from refined diffraction patterns using the orthorhombic  $\beta$  polymorph.<sup>50, 51</sup>

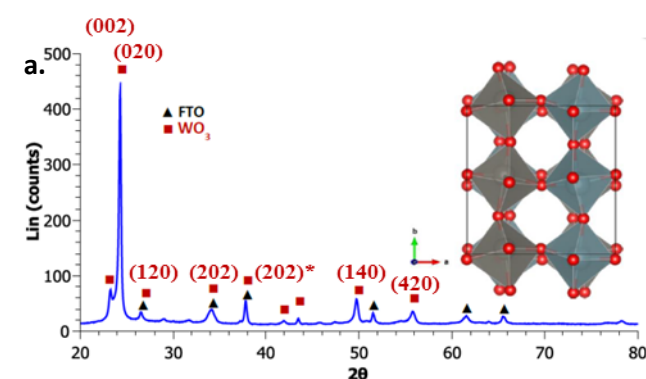


Fig. 1 XRD Cu K $\alpha$  pattern of mesoporous WO<sub>3</sub> (indicated by red squares and indexed peaks are labelled in red for the orthorhombic phase, only one peak corresponds to orthorhombic phase, noted \*) on glass FTO substrate (triangles).

X-ray diffraction patterns (XRD) suggest the WO<sub>3</sub> crystal system orients orthorhombic along the *a*-plane and monoclinic in *b/c* plane shown in Fig. 1. Lattice parameters are calculated to be 7.34 Å, 6.89 Å, and 7.65 Å for *a*, *b*, and *c* planes, respectively.

The WO<sub>3</sub> film is mesoporous, with an average thickness of 550 nm from 8 consecutive depositions by dip coating and possessing (Fig. 2). The pores have an average of 20 nm diameter size verified by HR-TEM (Fig. 2e, 2f). The film nanostructure is columnar, consisting of needle-shaped crystallites (see Fig. 2b, 2d). The needle cross-sections normal to their axis are randomly oriented in the plane perpendicular to the sample surface, while their *a*-axis is always well aligned along the direction normal to the sample surface (see Fig. 2b and 2d).

The WO<sub>3</sub> thin film is visually transparent with a slight yellow tint. The absorption and transmission spectra of WO<sub>3</sub> are seen in the UV-visible transmission spectrum in Fig. 3a. The absorption edge of WO<sub>3</sub>, according to UV-visible absorption spectra, is found around 430 nm confirming a large band gap. This slight yellow tint indicates a large band gap, allowing shorter wavelengths to 430 nm to pass to the photocathode to be absorbed in an envisioned tandem dual photosystem photocatalytic cell configuration. The band gap of sol gel processed WO<sub>3</sub> was estimated from absorption and transmission data, using Tauc plot representation. A linear fit suggested a value of 2.89 eV (inserted in Fig. 3a).<sup>52</sup> Fringes are seen in the visible and near-infrared portion of the transmittance spectrum and are most likely due to the refraction of WO<sub>3</sub> pores and dip coated layers.

### 3.2. Photoelectrochemical Performance.

The photoelectrochemical performance of mesoporous WO<sub>3</sub> photoanode has been evaluated in a three electrode cell upon linear sweep voltage in pH 2 – 6 potassium phosphate solutions.

#### 3.2.1. Impact of the nanostructuration.

The impact of the nanostructuration on the photocurrent tested by linear voltage sweeps was measured on 550 nm thick mesoporous and dense thin films of WO<sub>3</sub> heat-treated at 400°C (Fig. 3b). Upon illumination, the onset potential decreases to 0.6 V vs. RHE – a major cathodic shift of 1.7 V comparable to other literature values.<sup>49</sup> Visible light response (400 nm – 950 nm) of WO<sub>3</sub> results in a photocurrent of up to 0.55 mA/cm<sup>2</sup> at 1.23 V vs. RHE with saturated photocurrent of 0.7 mA/cm<sup>2</sup> reached at 1.5 V vs. RHE under 300 mW/cm<sup>2</sup> Xenon lamp output power density. The mesoporous WO<sub>3</sub> thin film had a larger photocurrent response than the dense one (Fig. 3b). The photocurrent differences indicate that mesostructuration of thin films creates a larger surface area exposure to the electrolyte, increasing the photoelectrochemical performance for water splitting applications. After correction for film thickness, the 0.55 mA/cm<sup>2</sup> photocurrent value measured at 1.23 V vs. RHE under 100 mW/cm<sup>2</sup> visible-light illumination (see Fig S1, ESI) is comparable to that reported for another mesoporous WO<sub>3</sub> film reported by Yagi and coworkers.<sup>28</sup>

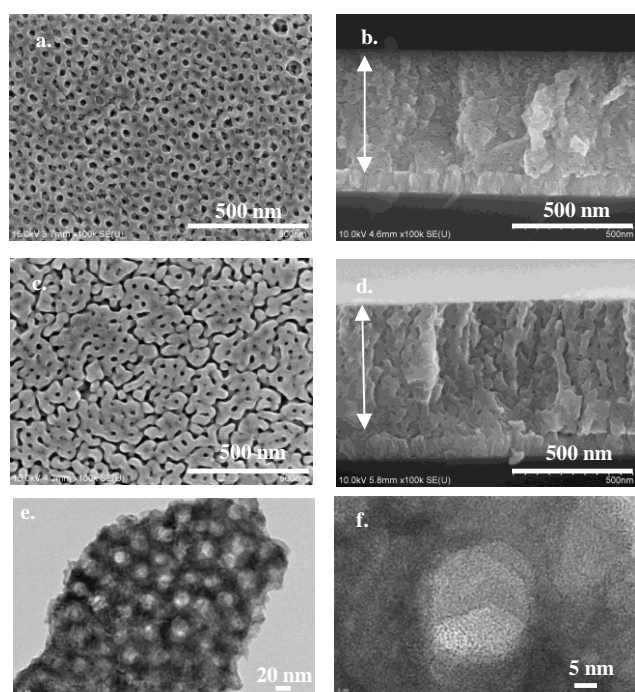


Fig. 2 FEG-SEM images of WO<sub>3</sub> thermally treated at (a) 400°C, (b) corresponding cross section at 400°C, (c) WO<sub>3</sub> thermally treated at 500°C and (d) cross section at 500°C,

(e,f) HR-TEM images of mesoporous WO<sub>3</sub> flakes calcined at 400°C dispersed in ethanol at 50k (e) and 400k magnification (f)

#### 3.2.2. Impact of the heat-treatment.

Thermal treatment of 400°C and 500°C in air was applied to WO<sub>3</sub> thin films to understand the impact of temperature on the photoelectrochemical performance. The layers treated at 500°C exhibited a slightly lesser photocurrent in acidic to neutral conditions than when treated at 400°C (Fig. 3c). This modification is attributed to the change of the porosity network upon thermal treatment at 500°C, as seen on FEG-SEM images in Fig. 2 (Fig. 2 b vs. 2d). The electrode/electrolyte interface is probably less developed in 500°C calcined thin films, decreasing the overall performance of the electrode.

#### 3.2.3. Understanding physical limitations of WO<sub>3</sub> mesoporous films

**Impact of UV light.** Upon removal of the ultraviolet optical filter (cut off 400 nm), the photocurrent of WO<sub>3</sub> is greatly increased due to the absorption of additional UV wavelengths as seen in Fig. 4a. This UV light (360 – 400 nm) addition increases photocurrent from 0.55 mA/cm<sup>2</sup> to 6.5 mA/cm<sup>2</sup> at 1.23 V vs. RHE under 350 mW/cm<sup>2</sup> illumination. This increase upon addition of UV light is in line with IPCE measurements (Fig. 4c). Under AM 1.5 G 100 mW/cm<sup>2</sup> illumination, the photocurrent value is 0.4 mA/cm<sup>2</sup> at 1.23 V vs. RHE Fig. 4a. Compared to other state of the art WO<sub>3</sub> photoanodes for the OER in a tandem dual photosystem, the dip coated FTO/WO<sub>3</sub> photoanode performance found in literature reports 2.7 mA/cm<sup>2</sup> for 6 μm of WO<sub>3</sub> under 100 mW/cm<sup>2</sup> illumination in pH 0 H<sub>2</sub>SO<sub>4</sub> at 1.4V vs. RHE. Seeing as our WO<sub>3</sub> photoelectrodes are 10x less thick, this suggests that the performances is comparable. The quantum yield or incident photon to current efficiency (IPCE) was measured using a 300 W Xenon lamp calibrated with a total power of 100 mW/cm<sup>2</sup> output in 1 M H<sub>2</sub>SO<sub>4</sub> (pH 0) between 300 – 600 nm. IPCE exhibits a maximum of 95% at 310 nm for mesoporous WO<sub>3</sub> treated at 400°C as shown in Fig. 4b. The UV-visible absorption spectra as well as WO<sub>3</sub> IPCE responses resemble very much those obtained by other groups.<sup>40</sup> Upon calculation of the light penetration depth from UV-visible absorbance measurements and thickness (shown in supplementary Fig. S2, ESI), it seems that all incident light of wavelengths up to 370 nm are absorbed. Absorption losses start to occur between 370 – 430 nm and efforts should be taken to increase absorption towards this range of the solar spectrum to increase future performance.

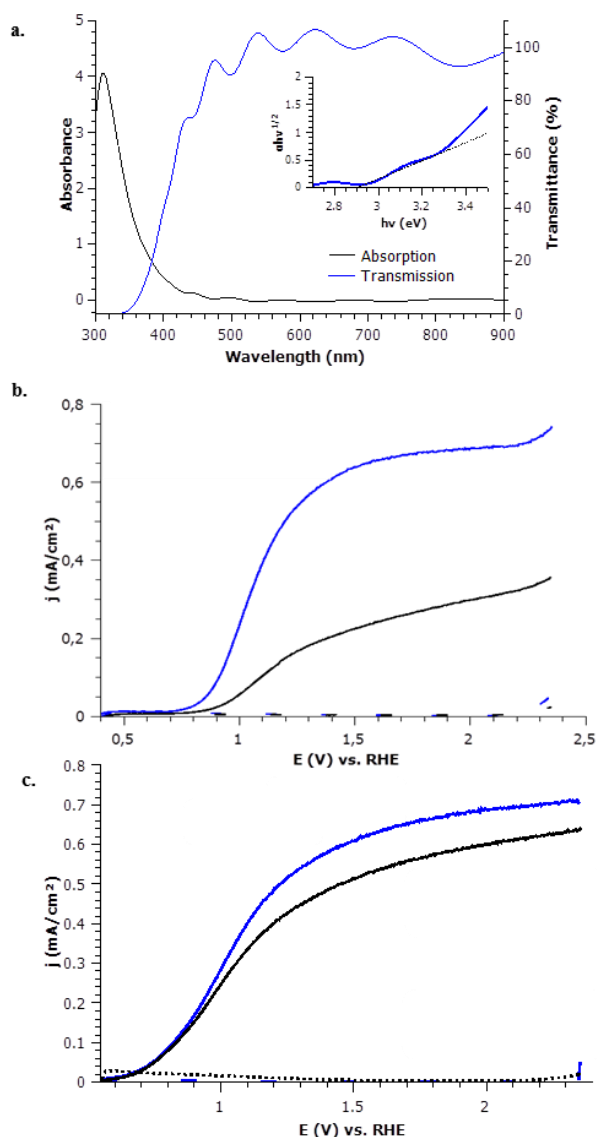


Fig.3 (a) UV–visible absorption (black) and transmission (blue) spectra of mesoporous WO<sub>3</sub> with interlaced Tauc plot suggesting band gap of 2.89 eV, (b) Linear voltage sweep of mesoporous (blue) and dense (black) WO<sub>3</sub> electrodes in 1 M potassium phosphate solution under visible light with corresponding FEG-SEM, (c) Linear voltage sweep of mesoporous WO<sub>3</sub> thermally treated at 400°C (blue) and 500°C (black) upon visible illumination

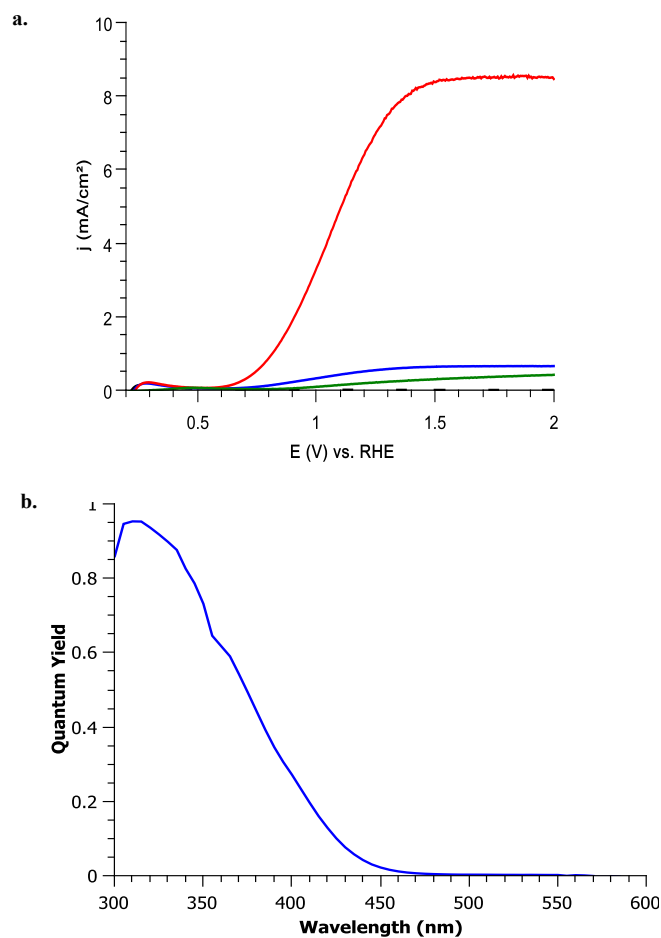


Fig. 4 (a) WO<sub>3</sub> linear voltage scan in 1 M (pH 6) potassium phosphate buffer under 300 mW/cm<sup>2</sup> visible light illumination (blue) and with addition of UV light (350 mW/cm<sup>2</sup>, red), and under AM1.5 (in green) (b) Quantum yield of mesoporous WO<sub>3</sub> at 1.23 V vs. RHE in 1 M H<sub>2</sub>SO<sub>4</sub> (pH 0)

To further understand the physical limitations and characteristics of the WO<sub>3</sub> mesoporous films, electrochemical impedance measurements were conducted in 1 M potassium phosphate to measure the flat band potential ( $E_{FB}$ ) by Mott-Schottky technique (Fig. S3, ESI). Measurements taken at 1000 Hz with 10 mV amplitude suggest that the  $E_{FB}$  of WO<sub>3</sub> is at 0.37 V vs. RHE (shown by dotted line in Fig. S3, ESI). This measured flat band value compared well with thin film WO<sub>3</sub> photoanodes.<sup>24, 53</sup> This value, compared to the illuminated onset potential (0.60 vs. RHE) in Fig. 4, indicates an OER overpotential requirement of >0.2 V for this WO<sub>3</sub> photoanode. The difference between the flat band potential and the onset value of photocurrent is related to fast recombination of photogenerated carriers together with slow OER kinetics at the material-electrolyte interface.

The impact of light intensity was then studied to determine whether the reaction is limited by surface kinetic or by



photocurrent generation. Upon increasing the light intensity from 100 mW/cm<sup>2</sup> to 300 mW/cm<sup>2</sup> a linear trend is observed for the WO<sub>3</sub> mesoporous thin films regarding the current density and light intensity (shown in supplementary information Fig. S2, ESI). Thus, charge carrier generation and/or recombination in the bulk material is a potential rate limiting step in WO<sub>3</sub> for the OER. These efficiency limiting processes are generally observed with large band gap semiconductors.<sup>24</sup> The linear response of photocurrent with light intensity suggest that surface oxidation kinetics do not participate in limiting overall photoelectrochemical performance of mesoporous sol-gel process thin film WO<sub>3</sub> photoanodes under these conditions.

**Surface limitation.** To confirm that surface oxidation kinetics do not participate in limiting overall photoelectrochemical performance in these mesoporous WO<sub>3</sub> photoanode, photocurrent was tested with chopped light under chronoamperometric conditions at 1.23 V vs. RHE (Fig. 5a).

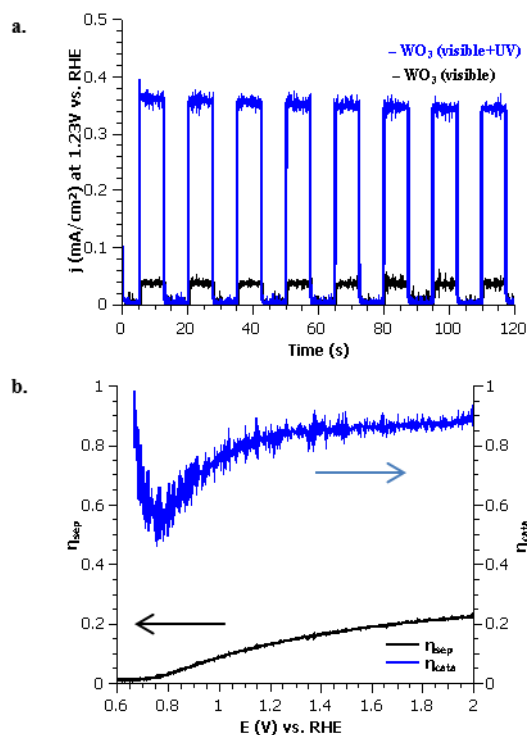


Fig. 5 (a) Light response of WO<sub>3</sub> under 100 mW/cm<sup>2</sup> visible irradiation (black) and upon addition of UV light (blue), (b) Charge separation efficiency (black) and surface catalytic efficiency of WO<sub>3</sub> in 1 M potassium phosphate buffer (pH 6) under 100 mW/cm<sup>2</sup> illumination using a sacrificial reagent 1 M H<sub>2</sub>O<sub>2</sub>

The photocurrent current displays a square response, suggesting the photoresponse to light is rapid, exhibiting no transient photocurrent. This behavior suggests that the surface extraction of holes is more rapid than the arrival charge carriers at the semiconductor liquid junction (SCLJ). Therefore, overall efficiency is limited by material bulk properties.

To better quantify the surface reactivity, a sacrificial reagent (1 M H<sub>2</sub>O<sub>2</sub> or Na<sub>2</sub>SO<sub>3</sub>) was added to the electrolyte (Fig. 5b). Under these conditions, 100% surface catalytic efficiency can be assumed due to the kinetically favoured reactions with the reagent anions compared to the kinetically restrained OER. The method of Dotan, et al. was used to quantify absorption losses under AM1.5G irradiation conditions.<sup>54</sup> The mesoporous WO<sub>3</sub> thin films absorb only 55% of the light considering a band gap of 2.89 eV. This limits the theoretical maximum photocurrent to 2.13 mA/cm<sup>2</sup> compared to the theoretical maximum of 3.88 mA/cm<sup>2</sup> (obtained by integration of the AM1.5G spectra assuming no optical or quantum losses for a band gap of 3.89 eV). The photoelectrochemical performance by linear voltage sweeps under AM1.5G illumination using an Oriel AM1.5G filter and a Xenon lamp with an output of 100 mW/cm<sup>2</sup> display a photocurrent of only 0.34 mA/cm<sup>2</sup>. Upon the addition of the sacrificial reagent, this photocurrent only slightly increased to 0.40 mA/cm<sup>2</sup> at 1.23 V vs. RHE. Assuming 100% surface catalytic efficiency for the photocurrent with sacrificial reagent, this corresponds to a charge separation efficiency of only 18%. Therefore a surface catalytic efficiency of 85% at water splitting potentials in potassium phosphate buffer was determined (displayed in Fig. 6b).

To confirm that conductivity of WO<sub>3</sub> is the limiting factor in these mesoporous WO<sub>3</sub> films, time resolved microwave conductivity (TRMC) measurements were performed to obtain charge carrier mobility ( $\mu$ ) and lifetime ( $\tau$ ) from the change in the photoconductance of the WO<sub>3</sub> mesoporous thin film (shown in Table S1, ESI and Fig. S4, ESI).<sup>55</sup> The charge carrier diffusion lengths were calculated using the following relationship,  $L_D = \sqrt{\frac{\mu kT}{e}} \tau$ , where  $\mu$  is the mobility (m<sup>2</sup>V<sup>-1</sup>s<sup>-1</sup>),  $k$  is the Boltzmann constant, and  $T$  is the temperature (K),  $e$  is the electronic charge (C), and  $\tau$  is the charge carrier lifetime (sec). These measurements propose a maximum diffusion length of 130 nm in mesoporous WO<sub>3</sub>, slightly smaller to the one observed in the literature (150 nm).<sup>23</sup> For 550 nm thin films, these diffusion lengths are enough to extract holes at the SCLJ for the OER. This diffusion length could potentially be increased by doping WO<sub>3</sub> thin films or further optimization of the mesoporous network. Nevertheless, metal oxides are known to be poor absorbers of light and possess poor absorption coefficients.<sup>56</sup> WO<sub>3</sub> is an indirect band gap semiconductor (necessitating phonons in addition to photons in order to photogenerate charge carriers). Indirect semiconductors generally require thicker layers for increased light absorption for effective photogenerated charge carrier generation. This is reflected in literature studies concerning WO<sub>3</sub> as a photoanode, using thin film thicknesses of at least 1  $\mu$ m, which is twice as thick as the mesoporous thin film in this study.<sup>30, 32, 57-60</sup> The absorption spectra, IPCE measurements, and addition of a sacrificial reagent all suggest that there are absorption losses at lower wavelength energies which contribute to the

performance limitation of  $\text{WO}_3$  as well as the poor separation efficiency in the bulk material. Thus, optical absorption and internal bulk material conductivity seem to be the main limitations in photoelectrochemical activity in these mesoporous  $\text{WO}_3$  thin films used for the OER in water splitting applications.

### Stability

$\text{WO}_3$  mesoporous films were tested under constant illumination in potassium phosphate buffer at pH 2, 4, and 6 to further understand aspects which affect OER kinetics as well as stability and faradic efficiency. To test stability under continuous operation, the photocurrent and the faradic efficiency of  $\text{WO}_3$  photoanodes were measured in potassium phosphate buffer at pH 2, 4, and 6 at 1.5 V vs. RHE under 350 mW/cm<sup>2</sup> irradiation for 1 hour with UV–visible light (Fig. 6a and S5, ESI). The corresponding photocurrents are shown in Fig. S5a, ESI. A decrease in photocurrent and faradic efficiency were observed especially at high pH. The  $\text{WO}_3$  photocurrents decreased slowly overtime in pH 2, 4, and more considerably in pH 6. This decrease in photocurrent and faradic efficiency is directly related to the photo dissolution of  $\text{WO}_3$  (formation of  $\text{WO}_4^{2-}$  anions) in neutral to basic solutions, as indicated by the Pourbaix diagram for tungsten.<sup>35</sup> This corrosion is confirmed by post-mortem FEG–SEM analyses of the photoanodes after 1 hour of measurements (Fig. S6, ESI). Further, Fig. 6a indicates that the corrosion of  $\text{WO}_3$  only occurs for pH values > 4 under oxidizing conditions. The low faradaic efficiency observed may be attributed to the formation of peroxo species such as  $\text{S}_2\text{O}_8^{2-}$  at the surface of  $\text{WO}_3$  photoanode as it has been highlighted in <sup>61</sup>. Additionally, the slight decrease in photocurrent for  $\text{WO}_3$  photoanodes in acidic conditions may be due to blocking of the  $\text{WO}_3$  surface by peroxo species typically associated with incomplete  $\text{O}_2$  production or  $\text{O}_2$  bubble trapping at the surface of the electrode modifying the interface exposed to the electrolyte. It is thought that formation of  $\text{O}_2$  is preferred over peroxo species at higher pH.<sup>19c</sup>

### Impact of the addition of electrocatalyst.

Addition of a co-catalyst on photoelectrodes can potentially ameliorate the water splitting surface kinetics and reduce surface recombination. The impact of the addition of electrocatalyst on the surface of these mesoporous  $\text{WO}_3$  thin films was investigated (Fig. 6b). A reported OER electrocatalyst, cobalt phosphate (Co-Pi), was photo–electrodeposited onto the  $\text{WO}_3$  at pH 6, as it has been reported to increase the performance of  $\alpha\text{-Fe}_2\text{O}_3$ .<sup>62, 35</sup> According to the deposition conditions described in the experimental section, the quantity of electrocatalyst deposited was about 3% atomic cobalt constitution compared to tungsten onto the mesoporous  $\text{WO}_3$  thin film surface after 5 minutes. This was verified by EDX measurements (see Fig. S7, ESI). The linear voltage sweep photoresponse of a successful 5-minute Co-Pi deposition on

mesoporous  $\text{WO}_3$  compared to bare mesoporous  $\text{WO}_3$  is shown in Fig. 6b. The addition of Co-Pi failed to exert a cathodic shift of the onset potential; however, the photocurrent slightly increased compared to bare  $\text{WO}_3$  near the OER equilibrium potential.<sup>9</sup>

Faradic testing in 1 M potassium phosphate (pH 6) has been performed for bare mesoporous and for  $\text{WO}_3/\text{Co-Pi}$ . Initially, the  $\text{WO}_3/\text{Co-Pi}$  film had a larger  $\text{O}_2$  production than bare  $\text{WO}_3$  (Fig. 6c), but after time it exhibit faradic efficiency similar to that of the bare mesoporous  $\text{WO}_3$ . With time, the mesoporous  $\text{WO}_3$  thin films decorated with Co-Pi still corroded overtime. This observation may suggest that Co-Pi detaches from the surface and dissolves in the solution as it has been previously demonstrated in <sup>10, 63, 10, 64, 65 66, 67, 68,69</sup>.

## 4. CONCLUSION

Thin films of  $\text{WO}_3$  obtained by sol-gel dip coating appear to be a promising lead as low cost n-photoanode materials for use in acidic water splitting technologies.  $\text{WO}_3$  photoanodes for the OER were indeed successfully fabricated by the energy-efficient sol-gel dip coating method, furthermore allowing for a control of the microstructure of the films. Nanostructuration increases the performance. We have shown that the mesoporous films exhibit larger photocurrents than dense layers of  $\text{WO}_3$ , which is attributed to their larger specific surface area. The performance of our sol-gel dip coated  $\text{WO}_3$  compared with other reported work. At AM1.5 conditions, a photocurrent of 0.4 mA/cm<sup>2</sup> has been measured for roughly 550 – 600 nm thin films mesoporous  $\text{WO}_3$ . The surface, though struggling with peroxo species in acidic conditions and stability in neutral conditions, is not the rate limiting step for  $\text{WO}_3$ .

Photo–electrochemical measurements performed under various experimental conditions (e.g. pH, cell configuration, co-catalyst addition and stability, etc.) demonstrate that there is a compromise between stability and light-driven OER efficiency. Under acidic conditions,  $\text{WO}_3$  thin film photoanodes suffer from poor OER kinetics and an appropriate surface co-catalyst is required to increase the surface kinetics and favour the production of  $\text{O}_2$  over parasitic reactions. Though there are not many known OER co-catalysts stable in acidic conditions, further research is needed to lower the overpotential and increase photocurrent values at  $\text{WO}_3$  photoanodes under such conditions.



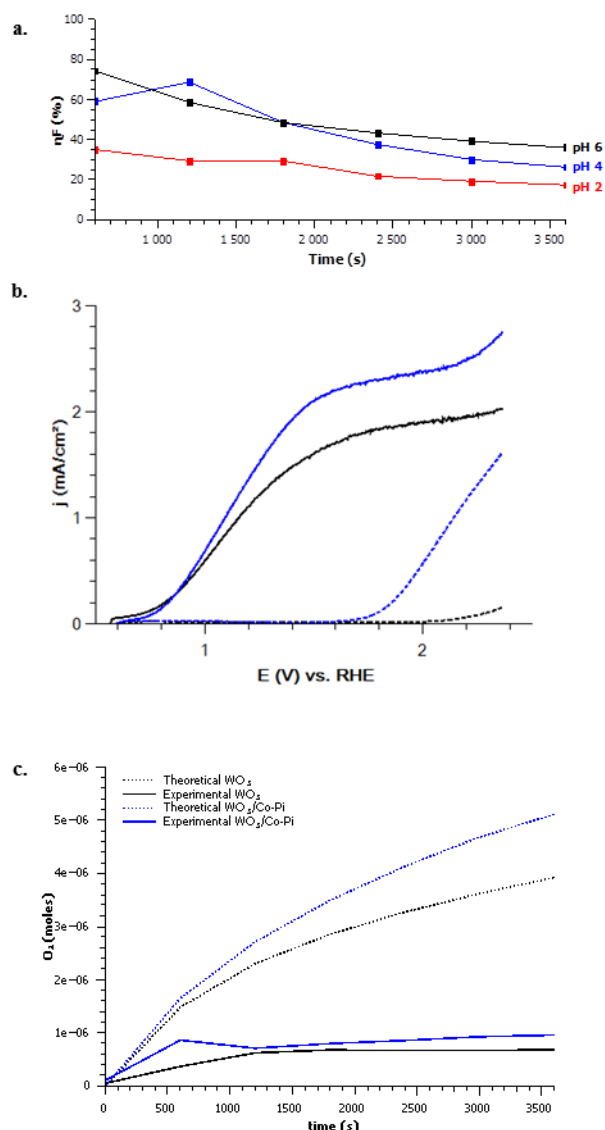


Fig. 6 (a) Faradic efficiencies measured by charge, gas chromatograph, and Clark electrode data from  $\text{WO}_3$  in 1 M potassium phosphate of varying pH at 1.5 V vs. RHE under  $300 \text{ mW/cm}^2$  irradiation, (b) Linear voltage sweep of  $\text{WO}_3$  (black, plain line : light, dash line: dark) and  $\text{WO}_3/\text{Co-Pi}$  (blue, plain line: light; dash line: dark) in 1 M potassium phosphate buffer (pH 6) under visible light ( $300 \text{ mW/cm}^2$ ) illumination, (c) Experimental moles of  $\text{O}_2$  measured (solid line) and theoretical moles (dotted line) of  $\text{O}_2$  calculated for  $\text{WO}_3$  (black) and  $\text{WO}_3/\text{Co-Pi}$  (blue) thin films in 1 M potassium phosphate buffer (pH 6) under  $300 \text{ mW/cm}^2$ .

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